QUESTIONNAIRE RE: PVD COATING OPTIONS

In order to provide you with the best possible coating solution, we would like to know the following about your coating requirements:

* What kind of substrate will the coating be applied on?
* What are the dimensions of the substrate? Length, width, height.

* What type of coating do you wish to deposit? Multilayer, composite, multi-elemental, including compounds (nitrides, carbides etc.).
* How many substrates will be coated at one time?
* Will the substrate be coated on all sides?
* What is your desired coating thickness?
* What is your desired productivity/deposition rate?
* What are your coating uniformity requirements?
* What is the coating area of the processing chamber? Diameter, height.
* Do you need single, double, or triple roundtable rotation?
* Would you prefer to use strictly filtered cathodic arc deposition (LAFAD™), or hybrid filtered-arc-assisted magnetron sputtering (FAAMS™)?
* Would you prefer compact DCAD-250C primary arc sources with frustoconical targets, planar sources with rectangular targets, or rotary sources with cylindrical targets?
* Are you interested in integrating our technology into an existing system, or constructing an entirely new system?
* Do you have any additional questions?

**Please provide the following contact information: your name, title, position, your company website address**

**PLEASE E-MAIL THE QUESTIONNAIRE WITH YOUR ANSWERS HERE:**

[info@nanoproductengineering.com](mailto:info@nanoproductengineering.com)